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CLAIMS

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What is claimed is:

1. An Aqueous Film Forming Foam formulation comprising R_F-Q_s, wherein:
R_F has a greater affinity for a first part of a system having at least two parts than Q_s;
Q_s has a greater affinity for a second part of the system than R_F; and
R_F comprises at least two -CF₃ groups and at least two hydrogens.

- 2. The formulation of claim 1 wherein R_F is hydrophobic relative to Q_s.
- 3. The formulation of claim 1 wherein Q_s is hydrophilic relative to R_F.
- 4. The formulation of claim 1 wherein R_F is hydrophobic and Q_s is hydrophilic.
- 10 5. The formulation of claim 1 wherein R_F comprises at least one -CH₂- group.
 - 6. The formulation of claim 1 wherein R_F comprises at least one cyclic group.
 - 7. The formulation of claim 6 wherein the cyclic group comprises an aromatic group.
- 15 8. The formulation of claim 1 wherein R_F comprises at least one (CF₃)₂CF-group.
 - 9. The formulation of claim 1 wherein R_F comprises at least three -CF₃ groups.
 - 10. The formulation of claim 1 wherein R_F comprises at least two $(CF_3)_2CF$ -groups.
- 20 11. The formulation of claim 1 wherein R_F comprises at least four carbons and one of the four carbons comprises a -CH₂- group.
 - 12. The formulation of claim 1 wherein $R_{\text{F}}\text{-}Q_{\text{s}}$ is $\bigcap_{R_{\text{F}}} \bigvee_{N} \bigcap_{N} \bigoplus_{N} \bigoplus_{N} \bigcap_{N} \bigoplus_{N} \bigoplus_{N$

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13. The formulation of claim 1 wherein R_F - Q_s is

14. The formulation of claim 1 wherein R_F-Q_s is ^{R_F}

15. The formulation of claim 1 wherein R_F-Q_s is ^F

16. The formulation of claim 1 wherein R_{F} - Q_{s} is

17. The formulation of claim 1 wherein R_F - Q_s is

18. The formulation of claim 1 wherein R_F - Q_s is

19. The formulation of claim 1 wherein R_F - Q_s is F_s C

20. The formulation of claim 1 wherein R_{F} - Q_{s} is F_{3} C

21. The formulation of claim 1 wherein R_F - Q_s is

10 22. The formulation of claim 1 wherein R_F-Q_s is

$$F_3C$$
 F
 CF_3
 CF_3
 CG
 CG
 G

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- 23. The formulation of claim 1 wherein R_F - Q_s is F
- 24. The formulation of claim 1 wherein R_F-Q_s is _F
- 25. The formulation of claim 1 wherein R_F - Q_s is F Q_s F.
- F₃C F_3 C F_3 C F
- 5 27. The formulation of claim 1 wherein R_F-Q_s is F₃C CF₃.
 - 28. The formulation of claim 1 wherein R_{F} - Q_{s} is F_{3} C

 - 30. The formulation of claim 1 wherein R_F - Q_s is $F_3C \sum_{F_2}^{F_2} C \sum_{F_2}^{F_2} C \sum_{F_2}^{C} C \sum_{F_2}^{C}$
 - 31. The formulation of claim 1 wherein R_F - Q_s is F_3C F_3C F_3C CF_3

32. The formulation of claim 1 wherein $R_{F^*}Q_s$ is

33. The formulation of claim 1 wherein R_F - Q_s is

34. The formulation of claim 1 wherein R_F-Q_s is

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35. A process for providing an Aqueous Film Forming Foam formulation to a substrate, the Aqueous Film Forming Foam formulation comprising R_F - Q_s , wherein: R_F has a greater affinity for a first part of a system having at least two parts than Q_s ; Q_s has a greater affinity for a second part of the system than R_F ; and R_F comprises at least two -CF₃ groups and at least two hydrogens.

- 36. The process of claim 35 wherein R_F is hydrophobic relative to Q_s.
- 37. The process of claim 35 wherein Q_s is hydrophilic relative to R_F.
- 38. The process of claim 35 wherein R_F is hydrophobic and Q_s is hydrophilic.
- 39. The process of claim 35 wherein the substrate comprises a liquid.
- 40. The process of claim 35 wherein the substrate is a part of the system.
 - 41. The process of claim 35 wherein R_F comprises at least one -CH₂- group.
 - 42. The process of claim 35 wherein R_F comprises at least one cyclic group.
 - 43. The process of claim 42 wherein the cyclic group comprises an aromatic group.
- 20 44. The process of claim 35 wherein R_F comprises at least one (CF₃)₂CF- group.

- 45. The process of claim 35 wherein R_F comprises at least three -CF₃ groups.
- 46. The process of claim 35 wherein R_F comprises at least two (CF₃)₂CF- groups.
- 47. The process of claim 35 wherein R_F comprises at least four carbons and one of the four carbons comprises a -CH₂- group.

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48. The process of claim 35 wherein R_F-Q_s is

- 49. The process of claim 35 wherein R_F-Q_s is ^{R_F}
- 50. The process of claim 35 wherein R_{F} - Q_{s} is R_{F}
- 51. The process of claim 35 wherein R_F - Q_s is R_F
- 52. The process of claim 35 wherein R_F-Q_s is R_F
 - 53. The process of claim 35 wherein R_F - Q_S is R_F .
 - 54. The process of claim 35 wherein R_F-Q_s is R_F-Q_s is
 - 55. The process of claim 35 wherein R_F - Q_s is F_3 C F

56. The process of claim 35 wherein R_F-Q_s is F₃C O_s.

F₃C CF₃ CCF₃ Q₄

57. The process of claim 35 wherein R_F-Q_s is

F₃C CF₃ CCF₃ O Q

58. The process of claim 35 wherein R_F - Q_s is

59. The process of claim 35 wherein R_F-Q_s is _F

5 60. The process of claim 35 wherein R_F-Q_s is F

61. The process of claim 35 wherein R_F - Q_s is F Q_s F

62. The process of claim 35 wherein R_F - Q_s is

63. The process of claim 35 wherein R_F - Q_s is F₃C CF₃.

64. The process of claim 35 wherein R_F - Q_s is F_3 C CF_3

10 65. The process of claim 35 wherein R_F - Q_s is

66. The process of claim 35 wherein R_{F} - Q_{s} is

67. The process of claim 35 wherein R_F - Q_s is F_3C F R_2 F CF_3 .

F₃C F CF₃

68. The process of claim 35 wherein R_F-Q_s is

5 69. The process of claim 35 wherein R_F - Q_s is

70. The process of claim 35 wherein R_F-Q_s is

- 71. A foam stabilizer comprising R_F - Q_{FS} , wherein R_F is hydrophobic relative to Q_{FS} , R_F comprising at least two -CF₃ groups and at least two hydrogens.
- The stabilizer of claim 71 wherein R_F comprises at least one -CH₂- group.
 - 73. The stabilizer of claim 71 wherein R_F comprises at least one cyclic group.
 - 74. The stabilizer of claim 73 wherein the cyclic group comprises an aromatic group.
 - 75. The stabilizer of claim 71 wherein R_F comprises at least one (CF₃)₂CF- group.
- The stabilizer of claim 71 wherein R_F comprises at least three -CF₃ groups.
 - 77. The stabilizer of claim 71 wherein R_F comprises at least two $(CF_3)_2CF$ -groups.

78. The stabilizer of claim 71 wherein R_F comprises at least four carbons and one of the four carbons comprises a -CH₂- group.

- 79. The stabilizer of claim 71 wherein R_F-Q_{FS} is R_F-Q_{FS}
- - 81. The stabilizer of claim 71 wherein R_F - Q_{FS} is F_3C F .
 - 82. The stabilizer of claim 71 wherein R_F-Q_{FS} is F₃C Q_{Fs}.

- 83. The stabilizer of claim 71 wherein R_F-Q_{FS} is
- 10 84. The stabilizer of claim 71 wherein R_F - Q_{FS} is F_3C F_3 F_4 G_{F_3} G_{F_4}
 - 85. The stabilizer of claim 71 wherein R_F-Q_{FS} is _F
 - 86. The stabilizer of claim 71 wherein R_F-Q_{FS} is F
 - 87. The stabilizer of claim 71 wherein R_F - Q_{FS} is F Q_{Fa} F .

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F₃C CF₃

88. The stabilizer of claim 71 wherein R_{F} - Q_{FS} is

89. The stabilizer of claim 71 wherein R_F-Q_{FS} is F₃C CF₃.

90. The stabilizer of claim 71 wherein R_F-Q_{FS} is F₃C CF₃

93. The stabilizer of claim 71 wherein R_F - Q_{FS} is F_3C F_3C F_5C F_5C

10 94. The stabilizer of claim 71 wherein R_F - Q_{FS} is F_3C F_5C F_5

95. The stabilizer of claim 71 wherein R_{F} - Q_{FS} is

96. The stabilizer of claim 71 wherein R_F-Q_{FS} is F₃C ×, wherein X comprises a halogen.